

## Publikationen

(2014): Dielectric Material Options for Integrated Capacitors. In: ECS Journal of Solid State Science and Technology, vol. 3, no. 8. DOI: 10.1149/2.0101408jss.

(2011): Atomic Vapor Depositions of Ti-Ta-O thin films for Metal- Insulator-Metal applications. In: Thin Solid Films, vol. 519, no. 11, pp. 3831-3834. DOI: 10.1016/j.tsf.2011.01.239.

(2011): Electrical characteristics of Ti-Ta-O based MIM capacitors. In: Journal of Vacuum Science & Technology B, vol. 29, no. 1. DOI: 10.1116/1.3534020.

(2010): Investigations of thermal annealing effects on electrical and structural properties of SrTaO based MIM capacitor. In: Microelectronic Engineering, vol. 87, no. 12, pp. 2561-2564. DOI: 10.1016/j.mee.2010.07.015.